



Deposition Materials

PLASMIONIQUE offers a variety of materials for evaporation or sputtering. Please [Contact us](#) with your specific requirements. For convenience you may submit a [Request for Quote](#). A selection of available materials is shown here, **call or email us if you do not see your required pure or composite material.**

Material Name	Symbol	Material Name	Symbol
Aluminum	Al	Lead	Pb
Aluminum Copper	Al/Cu	Magnesium Fluoride	MgF ₂
Aluminum Oxide	Al ₂ O ₃	Magnesium Oxide	MgO
Aluminum Silicon Copper	Al/Si/Cu	Molybdenum	Mo
Aluminum Silicon	Al/Si	Nickel	Ni
Antimony	Sb	Nickel Chromium	Ni/Cr (Nichrome)
Barium Titanate	BaTiO ₃	Silicon (n-type)	Si
Bismuth	Bi	Silicon (p-type)	Si
Bismuth Ferrite	BiFeO ₃	Silicon (undoped)	Si
Boron Carbide	B ₄ C	Silicon Carbide	SiC
Chromium	Cr	Silicon Dioxide	SiO ₂
Cobalt	Co	Silver	Ag
Copper	Cu	Tantalum	Ta
Gadolinium	Gd	Tin	Sn
Germanium	Ge	Titanium	Ti
Gold	Au	Titanium Nitride	TiN
Hafnium	Hf	Tungsten	W
Hafnium Oxide	HfO ₂	Vanadium	V
Indium	In	Yttrium Oxide	Y ₂ O ₃
Indium Oxide	In ₂ O ₃	Zinc	Zn
Indium Tin Oxide (ITO)	In ₂ O ₃ /SnO ₂ , 90/10 wt%	Zinc Oxide	ZnO
Iridium	Ir	Zinc Oxide Alumina	ZnO/Al ₂ O ₃ (~2% doped)
Iron	Fe	Zirconium	Zr